## Method of Sealing 1.5mm×1.5mm Standard CMOS Chip Bonding Wires

Yiyan Li 10/12/2013

#### **Resin used:**

RTV112-White (2.8 fl oz)

#### Chip tested:

# (MOSIS V35G-AC) Homemade Transimpedance Amplifier Test Circuit:



3			÷
1 2 3 4 5 6 7	Yout_A gnd_A Ybiasp_A Yp_A Ym_A Pin6 Yout B	VDD_A Vbias1_F Vbias2_F Vbias3_F Vbias4_F gnd VDD	40 39 38 37 36 35 34
7 8 9 10 11 12 13 14 15 16	Yout_B Ybiasp_B YDD_B gnd_B Yp_B Ym_B Yout_C Ybiasp_C YDD_C	YDD Ybiasp_F Pin32 Pin31 Yout_E gnd_E YDD_E Ym_E Yp_E	34 33 32 31 30 29 28 27 26 25
17 18 19 20	үр_С gnd_C Ym_C Yp_D gnd_D	VDIASP_E Vout_D Vbiasp_D Vm_D VDD_D	24 23 22 21

## Tools used for sealing

#### 1. Stranded wire:

Using one branch of the stranded wires to daub the resin to the bottom of the bonding wires.







#### 2. Celestron 10X-150X Microscope, PC and Breadboard





#### Bread Board is used to fix and test the chip

## Sealing Result



Don't worry about the remaining resin at the right up side of the chip, it can be totally avoided.

The opening is for microfluidic experiments. Water (transparent) is already filled the opening in this figure.

## **Chip Testing Results**

Amplifiers A-E are tested with the following circuit. Since this experiment is just testing the effect of sealing, the amplifier performance are not tested in detail.



1_	Yout_A	YDD_A	40
_2	gnd_A	Ybias1_F	39
3	Ybiasp_A	Ybias2_F	38
4	Yp_A	Ybias3_F	37
5	Ym_A	Ybias4_F	36
6	Pin6	gnd	35
_7	Yout B	- VDD	34
8	Ybiasp_B	Ybiasp_F	33
9	VDD_B	Pin32	35
10	and B	Pin31	31
11	Yp_B	Yout_E	30
12	Ym_B	and_E	29
13	Vout C	YDD_E	28
14	Ubjach C	Ym_E	27
15		Yp_E	26
16		Vbiasp_E	25
17	and C	Yout_D	24
18		Ybiasp_D	23
19		Vm D	25
20	gnd_D	YDD_D	21
	_		

## **Chip Testing Results**



Amplifier A

#### **Amplifier B**







Notice: Channel 2 is input signal, Channel 1 is output signal

Amplifier D

#### Amplifier E